

LIST OF PUBLICATIONS CITED BY APPLICANT	Attorney Docket No. SEL 189	09/598,736 Serial No. Not Assigned
	Applicant Toru TAKAYAMA et al	
	Filing Date Herewith 06/21/00	Group 2811

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
<u>V</u>	5,594,569	01/14/97	Konuma et al	349	122	07/20/94
<u>V</u>	5,643,826	07/01/97	Ohtani et al	437	88	10/25/94
<u>V</u>	5,738,948	04/14/98	Ikeda et al	428	663	09/29/95
<u>V</u>	5,923,962	07/13/99	Ohtani et al	438	150	04/28/95

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	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
<u>V</u>	JP 5-263226	10/12/93	Fujitsu Ltd.	-	-	03/17/92
<u>V</u>	JP 7-130652	05/19/95	Semiconductor Energy Laboratory Co., Ltd.	-	-	10/29/93
<u>V</u>	JP 8-153722	06/11/96	Toshiba Corp.	-	-	09/29/95

OTHER PUBLICATIONS

(Including Author, Title, Date, Pertinent Pages)

<u>V</u>	Yoshida, T. et al, "A Full Color Thresholdless Antiferroelectric LCD Exhibiting Wide Viewing Angle with Fast Response Time," <i>SID 97 Digest</i> , pp. 841-844, 1997.
<u>V</u>	Furue, H. et al, "Characteristics and Driving Scheme of Polymer-Stabilized Monostable FLCD Exhibiting Fast Response Time and High Contrast Ratio with Gray-Scale Capability," <i>SID 98 Digest</i> , pp. 782-785, 1998.
<u>V</u>	Hoffman, D.W. et al, "The Compressive Stress Transition in Al.V.Zr.Nb and W Metal Films Sputtered at Low Working Pressures, <i>Thin Solid Films</i> , vol. 45, pp. 387-396, 1977.
<u>V</u>	English abstract re Japanese Patent Application No. JP 5-263226, published May 19, 1995.
<u>V</u>	English abstract re Japanese Patent Application No. JP 7-130652, published May 19, 1995.
<u>V</u>	English abstract re Japanese Patent Application No. JP 8-153722, published June 11, 1996.

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